

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	357	204/241.ccls. 204/239.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/02 11:24
L3	63	L2 and (electroplat\$ electrodeposit\$)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/02 11:50
L4	8411	(electroplat\$ electrodeposit\$) and (heat\$3) with (substrate workpiece work semiconductor wafer)	US-PGPUB	OR	ON	2008/09/02 12:11
L5	2687	(electroplat\$ electrodeposit\$) and (heat\$3) with (substrate workpiece work semiconductor wafer) with surface	US-PGPUB	OR	ON	2008/09/02 12:12
L6	11	(electroplat\$ electrodeposit\$).clm. and (heat\$3).clm. with (local\$3).clm.	US-PGPUB	OR	ON	2008/09/02 12:13
L7	59	(electroplat\$ electrodeposit\$) and (heat\$3).clm. with (local\$3).clm.	US-PGPUB	OR	ON	2008/09/02 12:14
L8	48	L7 not L6	US-PGPUB	OR	ON	2008/09/02 12:14
L9	860	("204" "205" "118" "216" "156" "427"). clas. and (local\$2 localiz\$3) with Heat \$3 and (semiconductor wafer microelectronic microfeature electronic)	US-PGPUB	OR	ON	2008/09/02 12:17

L10	191	("204" "205" "118" "216" "156" "427"). clas. and (local\$2 localiz\$3) with Heat \$3 with (surface) and (semiconductor wafer microelectronic microfeature electronic)	US-PGPUB	OR	ON	2008/09/02 12:17
L11	22	("204" "205" "118" "216" "156" "427"). clas. and (local\$2 localiz\$3) with Heat \$3 with adjacent and (semiconductor wafer microelectronic microfeature electronic)	US-PGPUB	OR	ON	2008/09/02 12:19
L12	45	("204" "205" "118" "216" "156" "427"). clas. and (local\$2 localiz\$3) with Heat \$3 with adjacent and (semiconductor wafer microelectronic microfeature electronic)	USPAT	OR	ON	2008/09/02 12:21
L13	4	("4217183" "5127362" "5580607" "5814365").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/09/02 12:24
L14	28	("4217183").URPN.	USPAT	OR	ON	2008/09/02 12:25
L15	58	("6042712").URPN.	USPAT	OR	ON	2008/09/02 12:27
L17	23	("6685817").URPN.	USPAT	OR	ON	2008/09/02 12:28

9/2/08 12:47:11 PM

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